

Processing and Test Results for SC Drift-tube Cavities

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ANL Developed Cavities for 0.1< β <0.5



RIA Drift-tube Cavity Team/Collaborators



Fabrication: Processing and Clean Techniques





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U.S. Department of Energy



Facilities: Clean Processing for SRF Cavities





- Clean techniques from DESY and Jefferson Lab
- Ultrapure high-pressure water rinse in clean area
 18 MΩ DI water @120 bar for 1-2 hours
- Clean room assembly of cavity, cryostat, couplers



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Electropolishing at ANL



Electropolishing yields:

- **Typically sub-micron surface roughness** •
- Lower rf losses and less "Q-slope" at 4 K





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Surface Resistance in SRF Drift-tube Cavities







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Summary

- Cavities substantially exceed the RIA performance goal
- Low rf losses (R_{RES}~3-8 nΩ), little "Q-slope", no significant field emission
- Current prototype cavities, couplers and tuners are realistic production designs
- Clean techniques may be used to repeatably achieve high gradients in drift-tube cavities
- Set a new standard for drift-tube cavity performance



